

# Journal of Photochemistry and Photobiology

A: Chemistry

Volume 216 (1) (2010)

---

**Asian Editor**

H. Masuhara

*(Ikoma City, Japan)*

**Associate Editor to Asian Editor**

K. Hashimoto

*(Tokyo, Japan)*

**European Editor**

M.M. Martin

*(Paris, France)*

**American Editor**

R. Schmehl

*(New Orleans, LA, USA)*

**Founding Editor**

R.P. Wayne

*(Oxford, UK)*

**Editorial Board**

A.U. Acuna (*Madrid, Spain*)

N.S. Allen (*Manchester, UK*)

P.F. Barbara (*Austin, TX, USA*)

F. Catalina (*Madrid, Spain*)

S.M.B. Costa (*Lisbon, Portugal*)

S. Das (*Trivandrum, India*)

J. Delaire (*Cachan, France*)

J.-P. Desvergne (*Talence, France*)

A. Douhal (*Toledo, Spain*)

H. Fukumura (*Sendai, Japan*)

K. Ghiggino (*Melbourne, Australia*)

D. Guldi (*Erlangen, Germany*)

J.L. Herek (*Enschede, The Netherlands*)

J. Hofkens (*Leuven, Belgium*)

C.E. Hoyle (*Hattiesburg, MS, USA*)

K.C. Hwang (*Taiwan, Republic of China*)

H. Inoue (*Tokyo, Japan*)

M. Irie (*Tokyo, Japan*)

J. Karpiuk (*Warszawa, Poland*)

H. Lemmetyinen (*Tampere, Finland*)

Y. Li (*Beijing, China*)

B. Marciniak (*Poznań, Poland*)

U. Mazzucato (*Perugia, Italy*)

T.J. Meyer (*Los Alamos, NM, USA*)

A. Mills (*Glasgow, UK*)

J.P. Mittal (*Mumbai, India*)

K. Mizuno (*Osaka, Japan*)

D.C. Neckers (*Bowling Green, OH, USA*)

E.T.J. Nibbering (*Berlin, Germany*)

B. Ohtani (*Sapporo, Japan*)

J.C. Polanyi (*Toronto, Ont., Canada*)

V. Ramamurthy (*New Orleans, LA, USA*)

I. Saito (*Koriyama, Japan*)

M. Sauer (*Bielefeld, Germany*)

J.C. Scaiano (*Ottawa, Ont., Canada*)

R.P. Steer (*Saskatoon, Sask., Canada*)

V. Sundström (*Lund, Sweden*)

C.H. Tung (*Beijing, China*)

N.J. Turro (*New York, NY, USA*)

B. Valeur (*Paris, France*)

K.-D. Warzecha (*Mülheim, Germany*)

M. Wasielewski (*Evanston, IL, USA*)

V.W.W. Yam (*Hong Kong, PR China*)

G. Yang (*Beijing, China*)

M. Yoon (*Daejeon, Korea*)



ELSEVIER

Amsterdam • Boston • London • New York • Oxford •

Paris • Philadelphia • San Diego • St. Louis